IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Inventor: Yukihiro INOUE

Group Art Unit: 2811

FJONES

Appln. No.:

09/768,556

Examiner: S. Gebremariam

1-10-07

Filed:

January 25, 2001

For:

SEMICONDUCTOR DEVICE

**FAX RECEIVED** 

AMENDMENT

JAN 8 - 2003

Assistant Commissioner of Patents Washington, D.C. 20231

**TECHNOLOGY CENTER 2800** 

Sir:

Please amend the above-captioned application as follows:

## IN THE CLAIMS:

Please cancel claims 9 and 10, without prejudice or disclaimer.

Please amend the claims to read as follows (Exhibit I contains a marked up version):

- 5. (Twice Amended) A semiconductor device according to claim 13 wherein said diffusion layer of the first conductivity type is a channel stopper region.
- 6. (Twice Amended) A semiconductor device according to claim 14 wherein said diffusion layer of the first conductivity type is a channel stopper region.